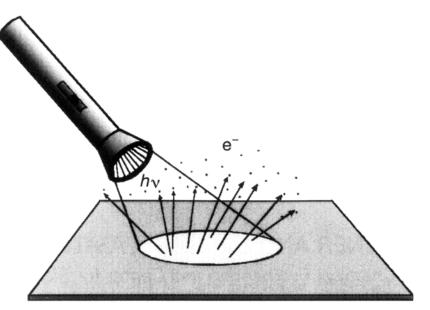
X-ray Photoelectron Spectroscopy

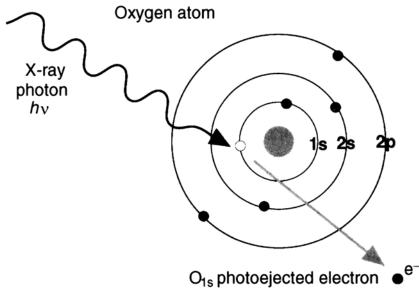
Roger Smart, Stewart McIntyre, Mike Bancroft, Igor Bello & Friends Department of Physics and Materials Science City University of Hong Kong Surface Science Western, UWO

Introduction

Photoelectric effect

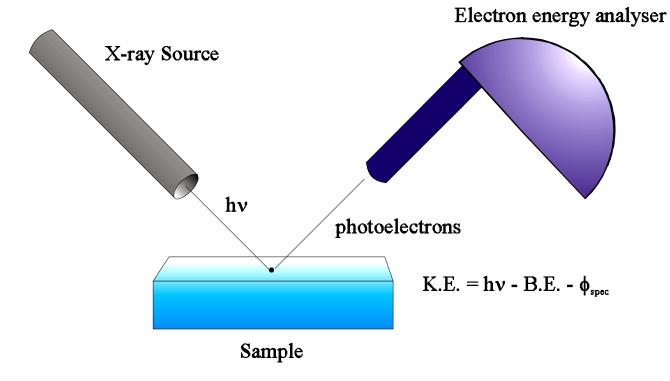
Photoelectric effect Einstein, Nobel Prize 1921





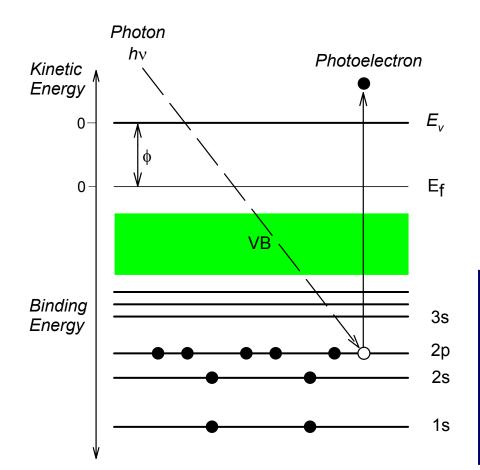
Photoemission as an analytical tool Kai Siegbahn, Nobel Prize 1981 XPS, also known as ESCA, is the most widely used surface analysis technique because of its relative simplicity in use and data interpretation.

- **XPS** X-ray Photoelectron Spectroscopy
- **ESCA** Electron Spectroscopy for Chemical Analysis
- **UPS** Ultraviolet Photoelectron Spectroscopy
- **PES** Photoemission Spectroscopy



Analytical Methods

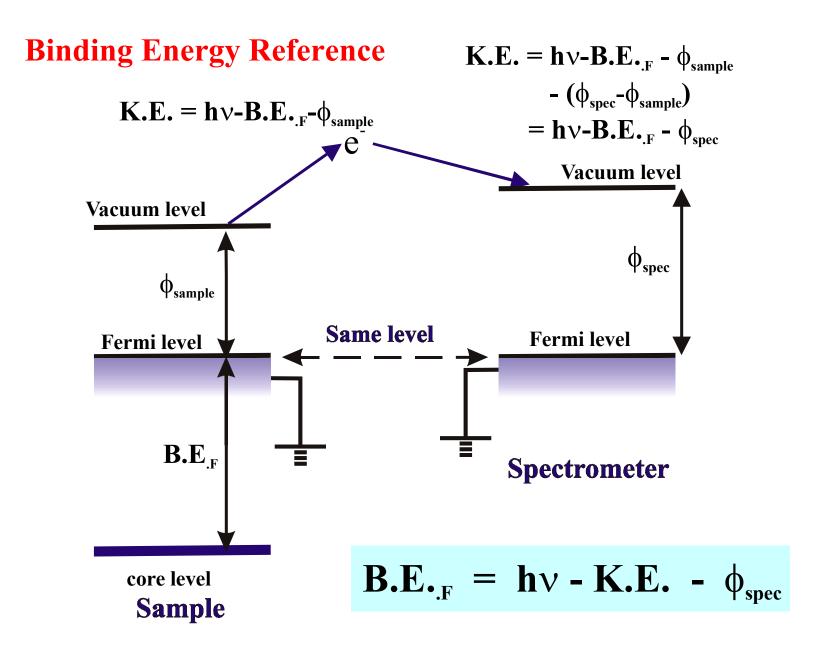
--- X-ray Photoelectron Spectroscopy (XPS)



$$KE = hv - (E_B + \varphi)$$

XPS spectrum: Intensities of photoelectrons versus E_B **or** KE

- Elemental identification and chemical state of element
- Relative composition of the constituents in the surface region
- Valence band structure

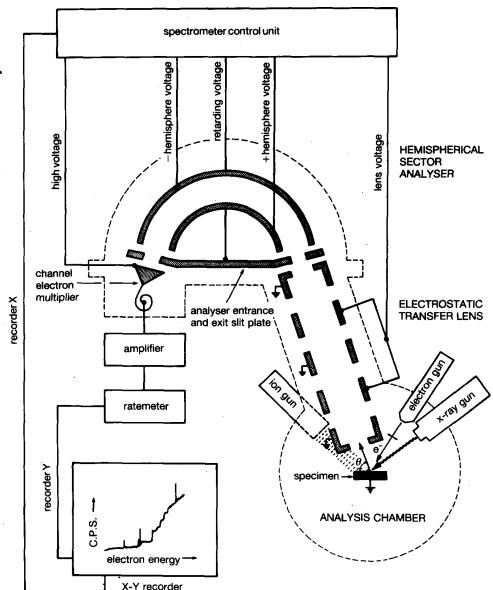


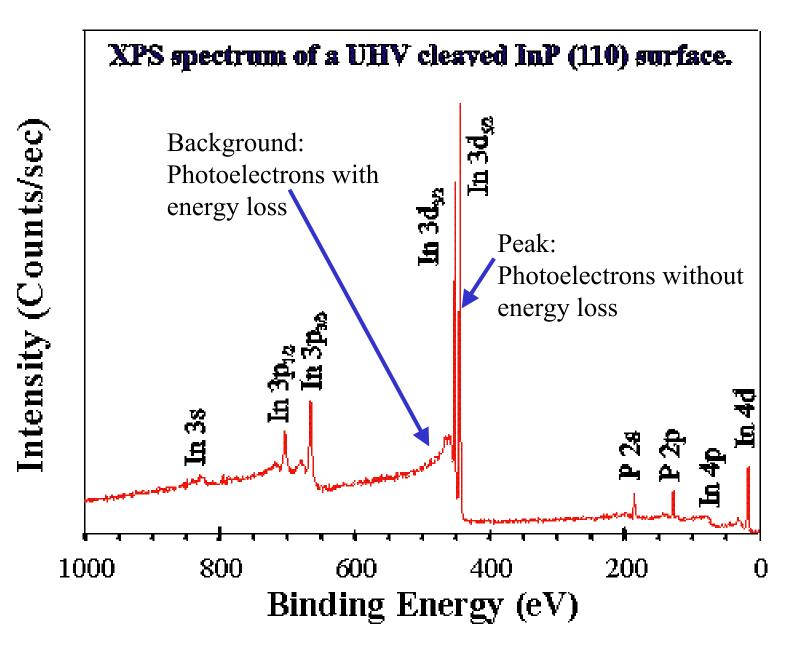
Instrumentation

- Electron energy analyzer
- X-ray source
- Ar ion gun
- Neutralizer
- Vacuum system
- Electronic controls
- Computer system

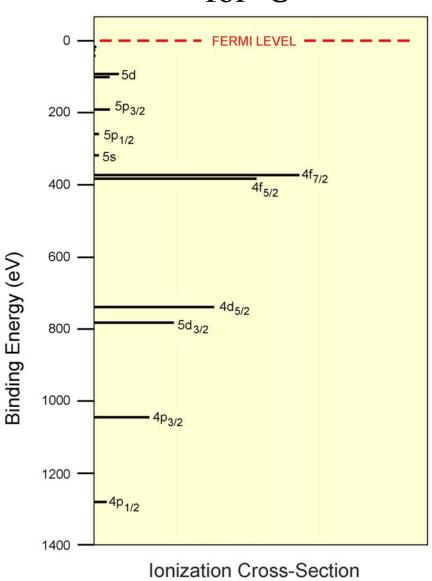
Ultrahigh vacuum system < 10⁻⁹ Torr (< 10⁻⁷ Pa)

- Detection of electrons
- Avoid surface reactions/ contaminations





Relative binding energies and ionization cross-section for U



For p, d and f peaks, two peaks are observed.

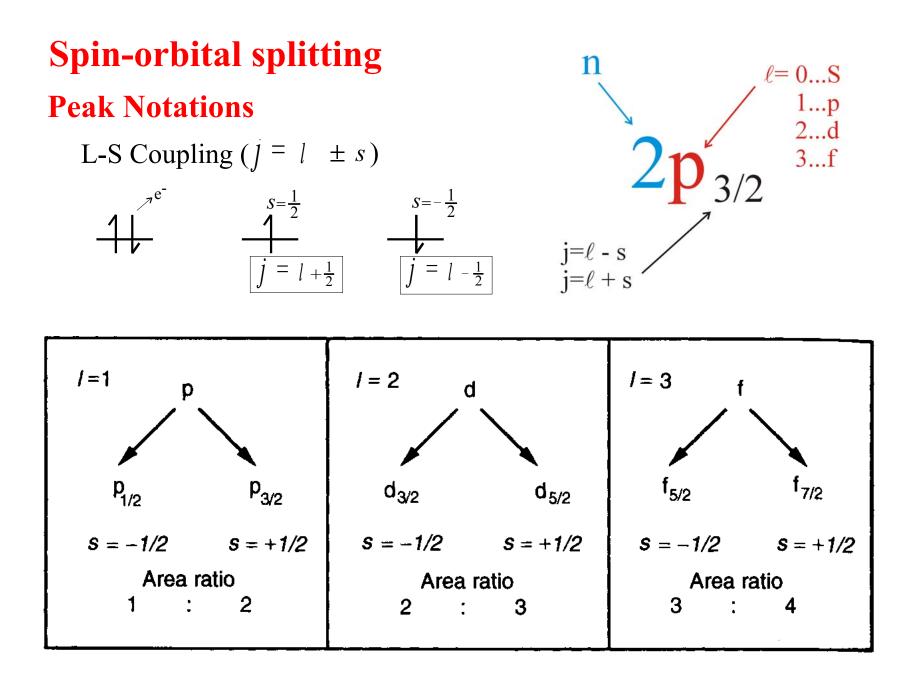
The separation between the two peaks are named **spin orbital splitting**. The values of spin orbital splitting of a core level of an element in different compounds are nearly the same.

Au

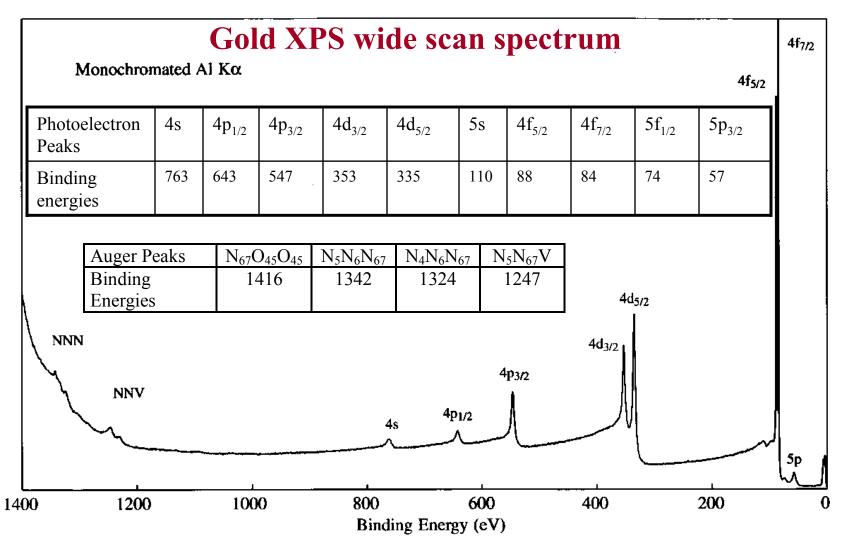
4d3/2

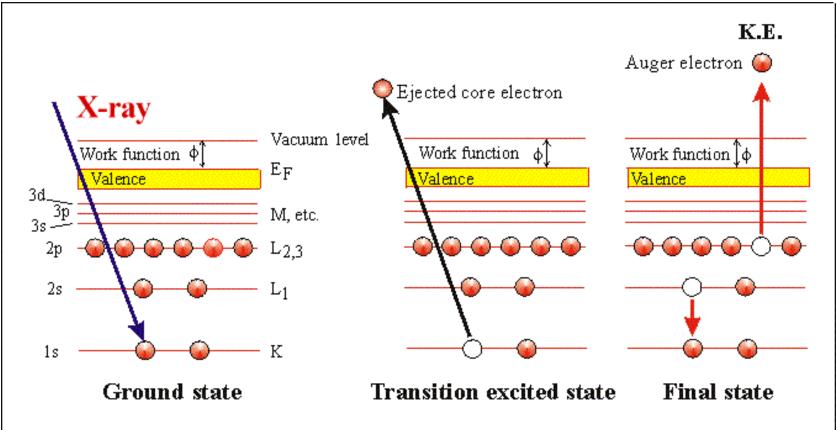
The **peak area ratios** of a core level of an element in different compounds are also nearly the same.

Spin orbital splitting and peak area ratios assist in element identifications.



Qualitative analysis



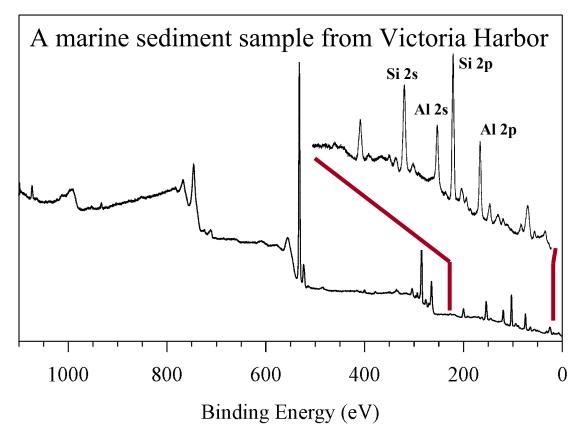


X-ray Induced Auger Electrons

K.E. is independent of the x-ray photon energy. However, in the B.E. scale, Auger peak positions depend on the x-ray source.

General methods in assisting peak identification

(1) Check peak positions and relative peak intensities of 2 or more peaks (photoemission lines and Auger lines) of an element
 (2) Check spin orbital splitting and area ratios for p, d, f peaks

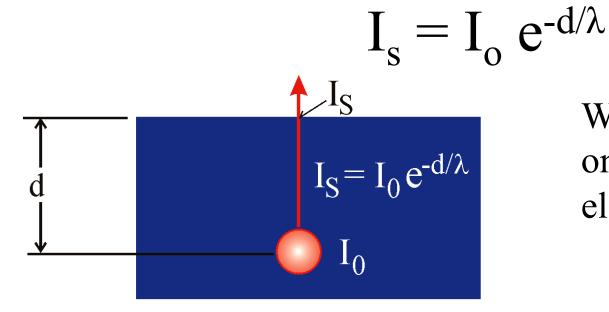


The following elements were found: O, C, Cl, Si, F, N, S, Al, Na, Fe, K, Cu, Mn, Ca, Cr, Ni, Sn, Zn, Ti, Pb, V

XPS Sampling Depth

 λ_i = inelastic mean free path of an electron in a solid

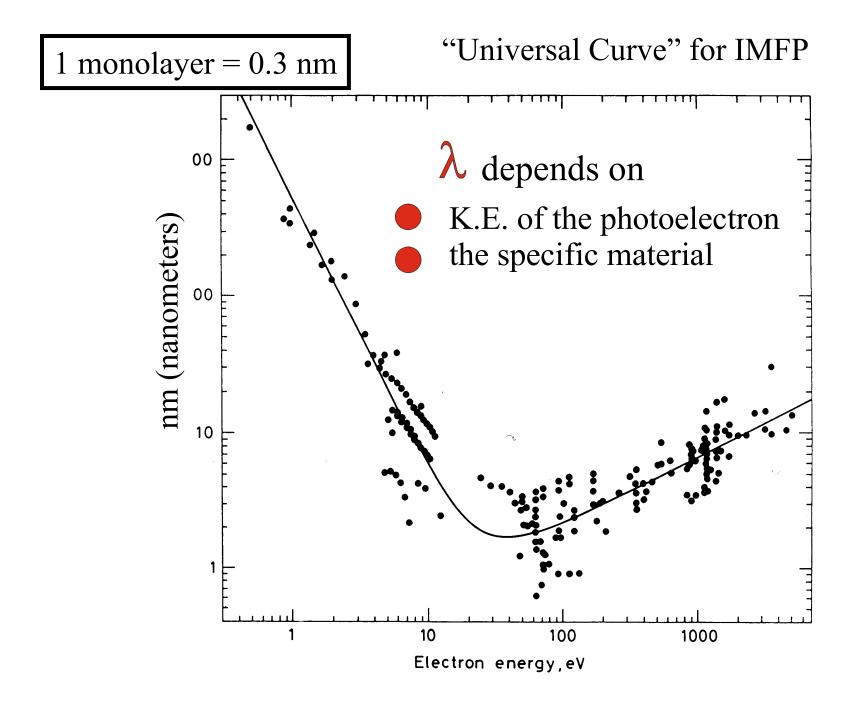
For an electron of intensity I_o emitted at a depth d below The surface, the intensity is attenuated according to the Beer-Lambert law. So, the intensity I_s of the same electron as it reaches the surface is



With a path length of one λ 63% of all electrons are scattered

Sampling Depth

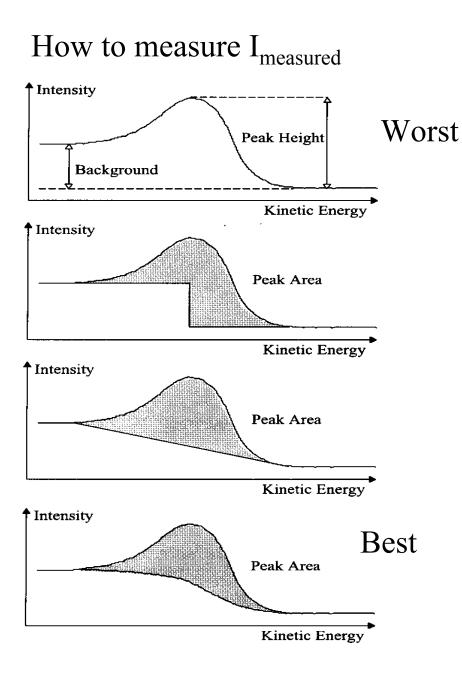
- Sampling Depth is defined as the depth from which 95% of all photoelectrons are scattered by the time they reach the surface (3λ)
- Most λ 's are in the range of 1-3.5 nm for AlKa radiation
- So the sampling depth (3 λ) for XPS under these conditions is 3-10 nm



Quantitative XPS: I

Some XPS quantitative measurements are as accurate as $\pm 10\%$

- $I_i = N_i \sigma_i \lambda_i K$
- where: I_i = intensity of photoelectron peak "p" for element "i" N_i = average atomic concentration of element "i" in the surface under analysis
 - σ_i = photoelectron cross-section (Scofield factor) for element "i" as expressed by peak "p"
 - λ_i = inelastic mean free path of a photoelectron from element "i" as expressed by peak "p"
 - K = all other factors related to quantitative detection of a signal (assumed to remain constant during exp't)



Accuracy better than 15% using ASF's

Use of standards measured on same instrument or full expression above accuracy better than 5%

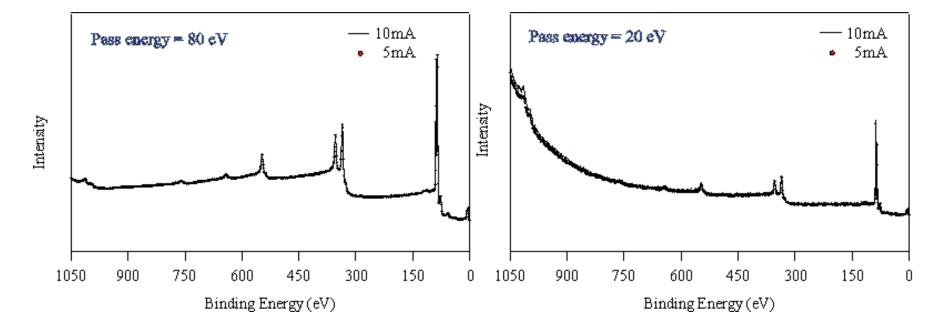
In both cases, reproducibility (precision) better than 2%

Must include or correct for (i) x-ray satellites (ii) chemically shifted species (iii) shake-up peaks (iv) plasmon or other losses

Transmission Function

Transmission function is the detection efficiency of the electron energy analyzer, which is a function of electron energies. Transmission function also depends on the parameters of the electron energy analyzer, such as pass energy.

Pure Au after Ar⁺ sputtering

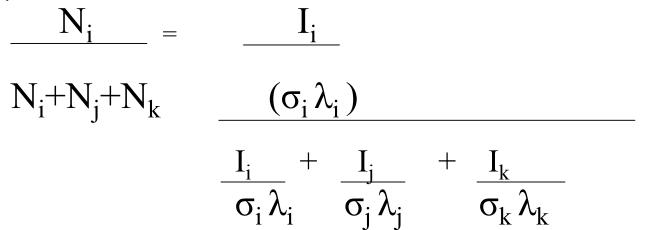


Quantitative Analysis: II

Scofield Cross-section Factors (σ_i **)** have been calculated for each element from scattering theory, specifically for AlK α and MgK α radiation

Inelastic Mean Free Paths (λ_i **)** varies with the kinetic energy of the photoelectron. It can be estimated from a "universal curve" or calculated (better).

For a multi-element surface layer consisting of elements i, j, k.



Examples of Quantitation I

Table 1. Oxide surfaces: oxygen/metal atomic ratios determined from corresponding line intensities

	Oxygen/metal atomic ratios*						
Oxide and form	0 2s/M 2p	0 2s/M 3p	0 2s/M 3d	O 1s/M 2s	0 1s/M 2p	0 1s/M 3p	0 1s/M 3p
MgO, pelletized powder	0.95 ± 0.1			1.1 ± 0.1	1.0 ± 0.1	_	
Al_2O_3 , thin film	1.55 ± 0.1	. 		1.5 ± 0.1	1.4 ± 0.1		-
SiO ₂ , several forms	1.55 ± 0.1			1.6 ± 0.1	1.6 ± 0.1	-	-
Fe_2O_3 , thin film		1.6 ± 0.2	_		6.0 ± 2.0	2.2 ± 0.2	
Cu ₂ O, thin film	0.5 ± 0.1	0.50 ± 0.1	_	_	0.5 ± 0.05		
ZnÖ, thin film		—			1.8 ± 0.2	1.05 ± 0.1	—
MoO_3 , thin film		—	2.95 ± 0.1	_	<u></u>	_	2.4 ± 0.1
CdO, pelletized powder	-			—	—	_	1.0 ± 0.1

* All ratios are the average of six measurements.

Examples of Quantitation II

Comparison of XPS and electron probe results for several feldspar minerals

	Atomic Composition*													
	PIA	G-02	PIAC	G-03	AL	B-2	AL	B-3	AN	0-1	LA	B-1	\ OLI	IG-1
Element	XPS	EPMA	XPS	EPMA	XPS	EPMA	XPS	EPMA	XPS	EPMA	XPS	EPMA	XPS	ЕРМА
Silicon (Si 2p)	27.3	29.3	25.5	24. 9	22.4	22.4	25.2	22.4	25.7	22.2	18.8	19.4	22.4	22.4
Aluminum (Al 2p)	11.9	12.4	15.0	15.6	8.4	8.3	9.3	8.4	7.2	8.6	11.0	11.4	8.4	8.6
Sodium (Na 2s)	5.7	6.6	2.3	3.2	4.3	7.2	8.4	6.6	4.5	6.6	4.4	3.6	7.9	6.3
Potassium (K 2p)	0.1	0.2	<0.1	0.2	<0.1	0.05	<0.1	0.12	< 0.1	0.2	<0.1	0.2	< 0.1	0.12
Calcium (Ca 2p)	2.2	3.7	4.9	9.0	0.6	0.6	0.9	0.8	2.1	0.9	3.1	3.9	0.8	1.0
Oxygen (O 1s)	52.8	47.8	52.3	47.1	64.3	61.5	56.2	61.8	59.4	61.6	62.8	61.6	60.5	61.7
Sum of % differences	9	.0	11	.5	4	.7	11	1.5	9 .	1	3.	9	3	.0

* Average of three determinations in the same location.

Errors in Quantitation

- I_i = sometimes difficult to separate "intrinsic" photoelectrons for the "extrinsic" scattered photoelectrons which comprise the background (± 5 - 100%)
- σ_i = calculated value (unknown magnitude)
- λ_i = estimated error $\pm 50\%$

Session 2

Chemical shifts in XPS

Initial and final states

Koopman's theorem

Equivalent core approximation

Calculations for binding energies and chemical shifts

Line widths and resolution

Chemical Effects in XPS

Chemical shift: change in binding energy of a core electron of an element due to a change in the chemical bonding of that element.

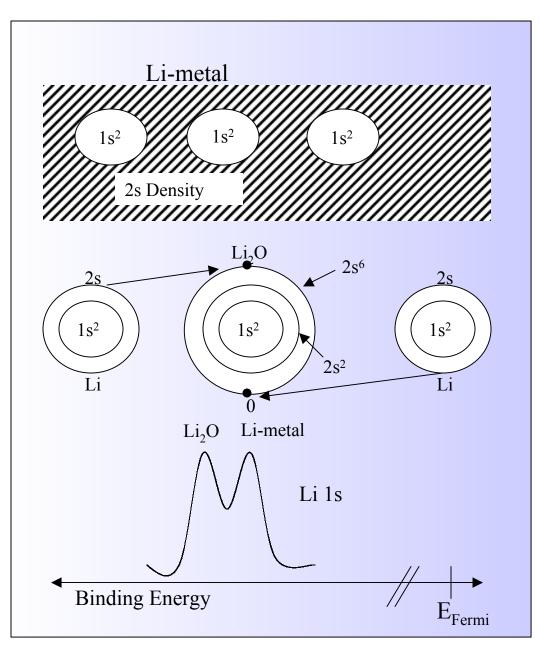
Qualitative view: Core binding energies are determined by:

- electrostatic interaction between it and the nucleus, and reduced by:
- the electrostatic shielding of the nuclear charge from all other electrons in the atom (including valence electrons)
- removal or addition of electronic charge as a result of changes in bonding will alter the shielding

Withdrawal of valence electron charge \longrightarrow increase in BE (oxidation)

Addition of valence electron charge —— decrease in BE

Chemical Shifts: Oxide Compared to Metal



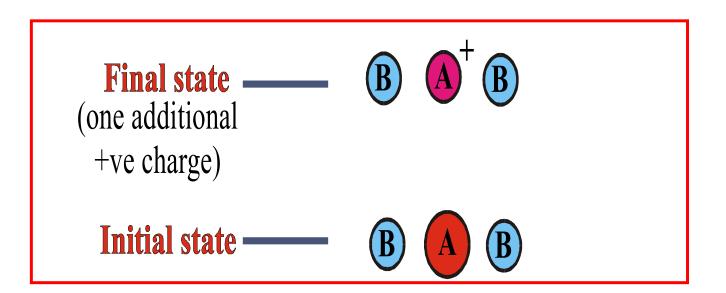
Binding Energy is lower due to increased screening of the nucleus by 2s conduction by 2s electrons

Binding Energy is higher because Li 2s electron density is lost to oxygen

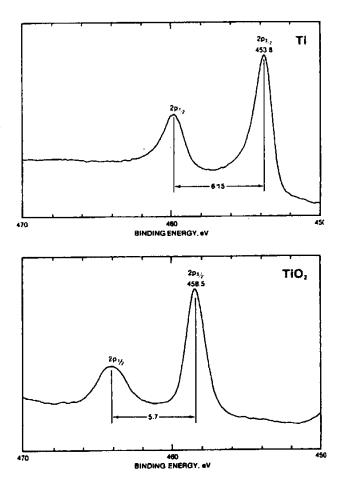
PE spectrum

Photoemission Process can be thought of as 3 steps:

- (a) Photon absorption and ionisation (initial state effects)
 (b) Response of atom and creation of photoelectron (final state effects)
- (c) Transport of electron to surface (extrinsic effects)



Usually chemical shifts are thought of as initial state effect (i.e. relaxation processes are similar magnitude in all cases)



Ti $2p_{1/2}$ and $2p_{3/2}$ chemical shift for Ti and Ti⁴⁺. Charge withdrawn Ti \rightarrow Ti⁴⁺ so 2p orbital relaxes to higher BE

Note: Spin-orbit splitting is approximately constant - confirming SOS is largely an initial state effect

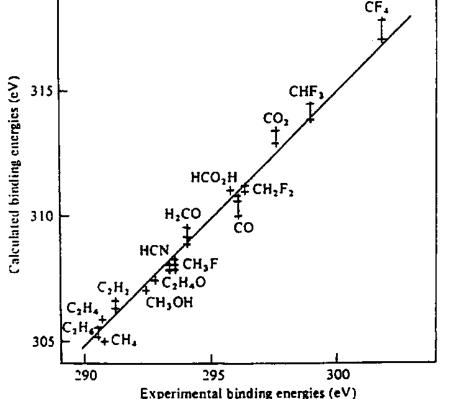
Chemical shift information very powerful tool for functional group, chemical environment, oxidation state

Koopman's Theorem

The BE of an electron is simply the difference between the initial state (atom with n electrons) and final state (atom with n-1electrons (ion) and free photoelectron)

$$BE = E_{final}(n-1) - E_{initial}(n)$$

If no relaxation* followed photoemission, BE = - orbital energy, which can be calculated from Hartree Fock. *this "relaxation" refers to electronic rearrangement following photoemission – not to be confused with relaxation of surface atoms.



Functional group		Binding energy (eV)
hydrocarbon	С–Н, <u>С</u> –С	285.0
amine	C-N	286.0
alcohol, ether	<u>С</u> -О-Н, <u>С</u> -О-С	286.5
Cl bound to carbon	<u>C</u> -C1	286.5
F bound to carbon	<u>C</u> F	287.8
carbonyl	<u>C</u> =0	288.0
amide	N− <u>C</u> =0	288.2
acid, ester	0~ <u>C</u> =0	289.0
urea	0 ⊪ N− <u>C</u> −N	289.0
carbamate	о- <u>с</u> -м	289.6
carbonate	o ≝ o− <u>c</u> −o	290.3
2F bound to carbon	$-CH_2CF_2-$	290.6
carbon in PTFE	-CF ₂ CF ₂ -	292.0
3F bound to carbon	-CF ₃	293-294

Table 3.2. Typical C1, binding energies for organic samples*

*The observed binding energies will depend on the specific environment where the functional groups are located. Most ranges are ± 0.2 eV, but some (e.g., fluorocarbon samples) can be larger

Table 3.3. Typical O1s binding energies for organic samples*

Functional group		Binding energy (eV)
carbonyl	C= <u>0</u> , 0–C= <u>0</u>	532.2
alcohol, ether	С <u>–О</u> –Н, С– <u>О</u> –С	532.8
ester	$C-\underline{O}-C=O$	533.7

*The observed binding energies will depend on the specific environment where the functional groups are located. Most ranges are ± 0.2 eV.

The Chemical Shift: Charged Sphere Model

 \mathbf{q}_{v}

 r_{v}

For a single atom j:

$$E = q_v e^2$$

$$r_v = no. of valence electrons$$

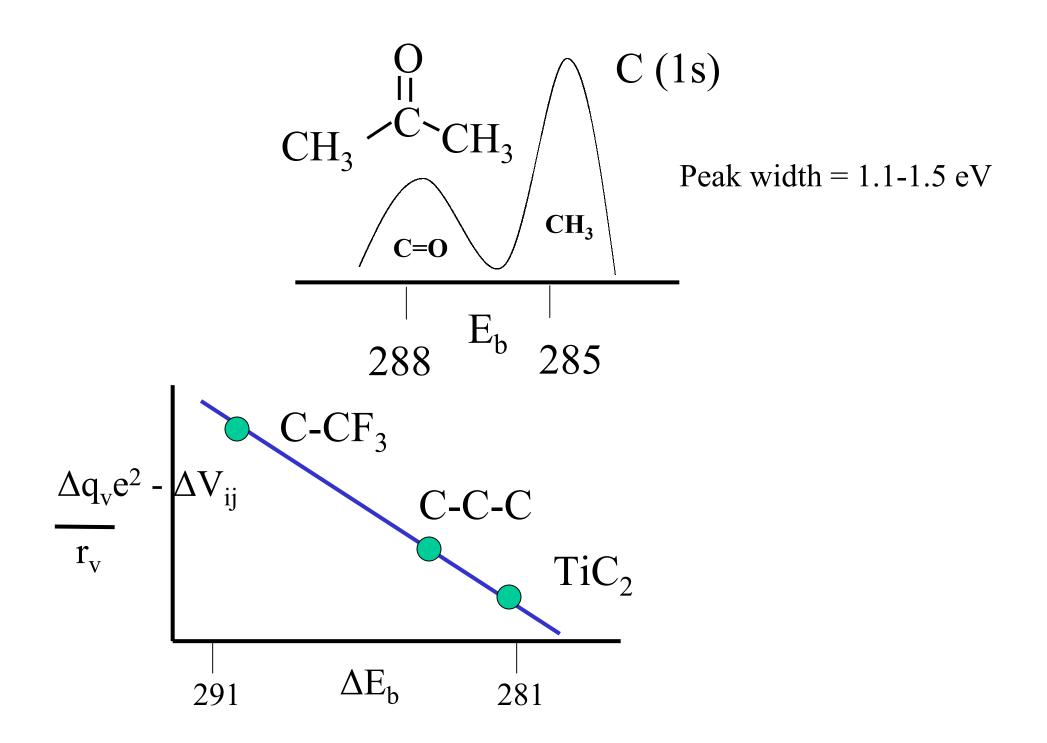
$$r_v = average radius of valence$$

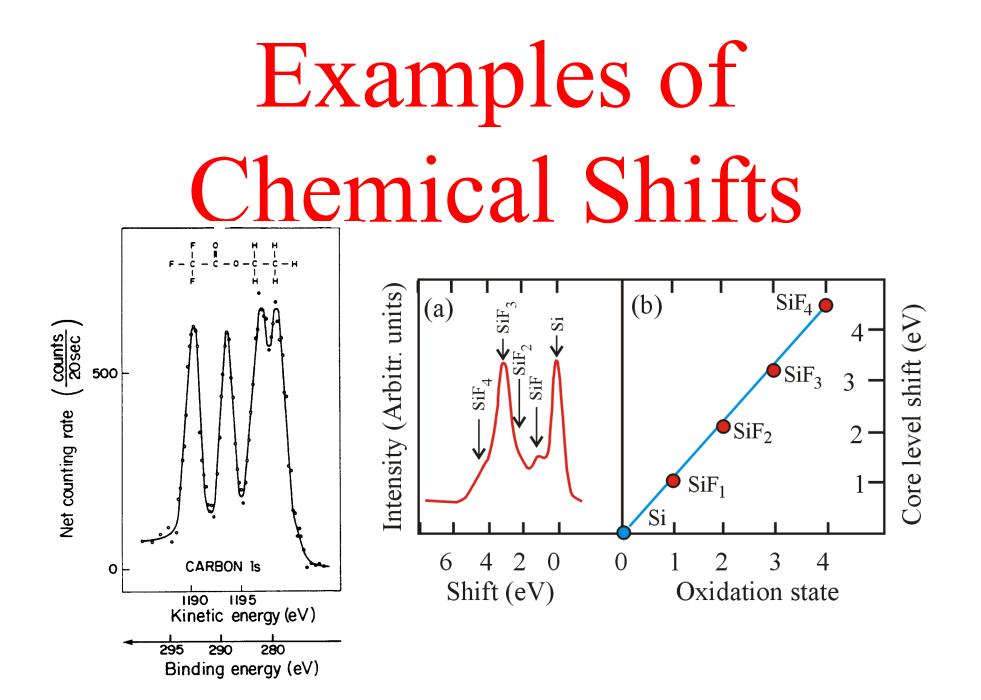
$$electrons$$

$$\Delta E_{b} = \Delta q_{v} e^{2}$$
$$r_{v}$$

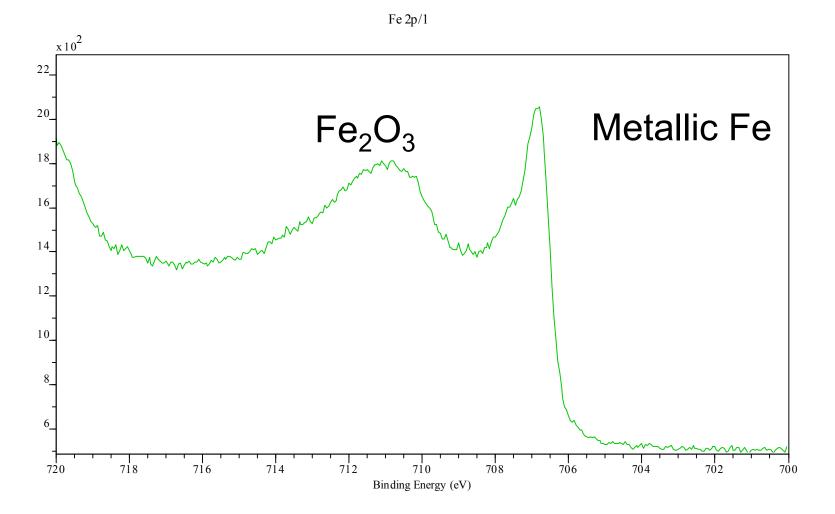
Add change in interatomic potential

$$E_b = \Delta q_v e^2 - \Delta V_{ij}$$
 where V_{ij} = potential of atom i on j
 r_v

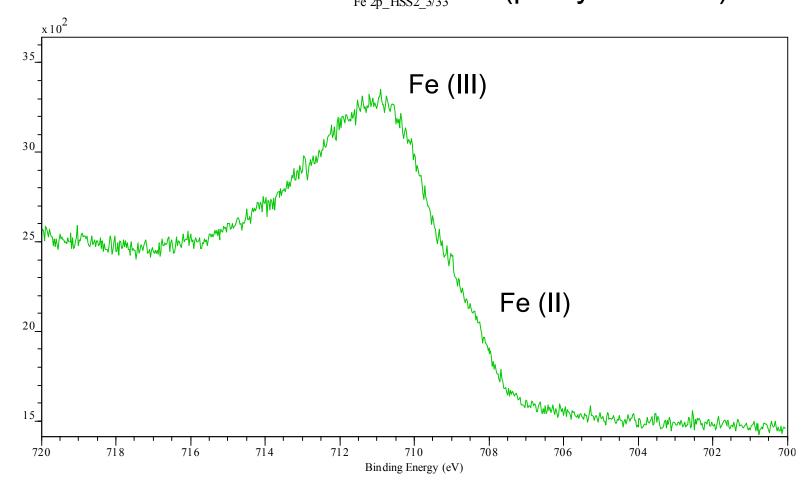




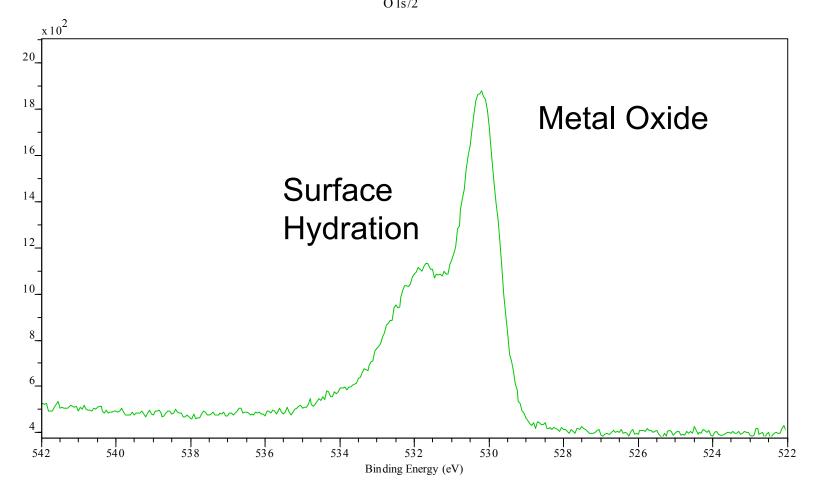
Detailed Iron 2p Spectrum of High Purity Iron

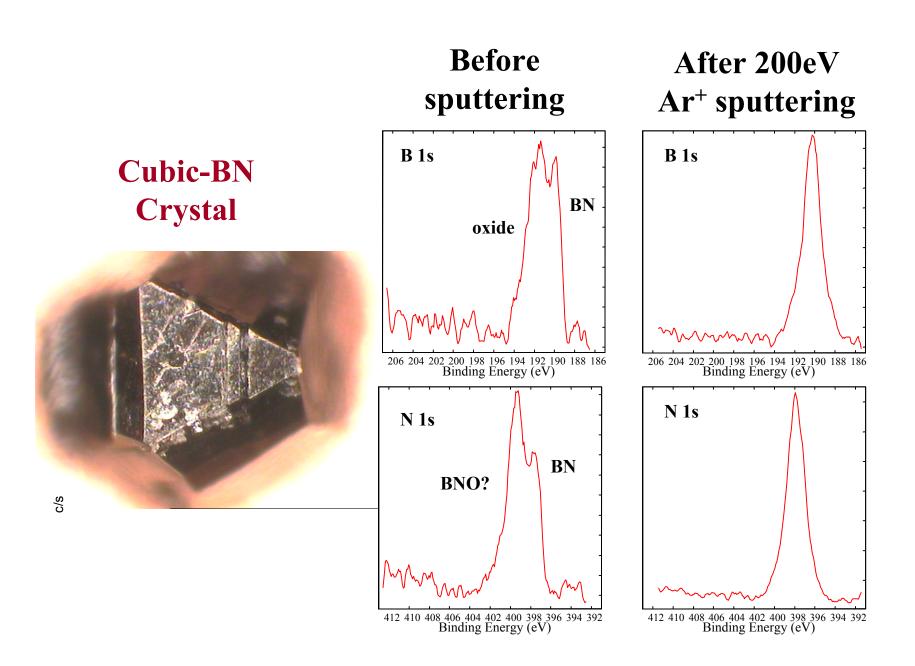


Detailed Spectrum of Fe 2p line for Magnetite Fe 2p HSS2 3/33 (partly oxidized)

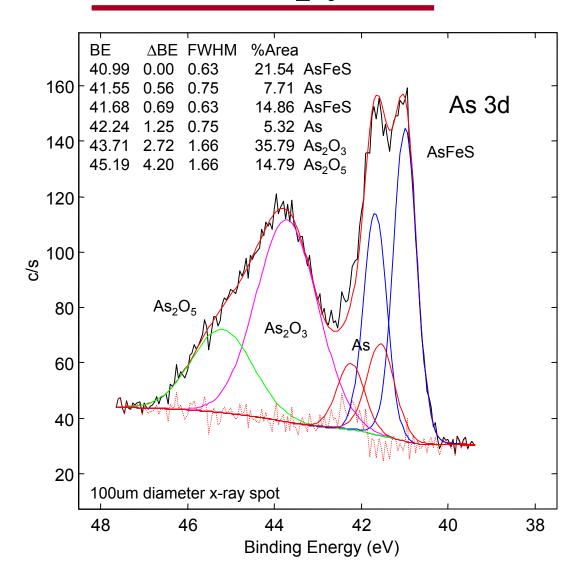


Detailed Oxygen 1s Spectrum

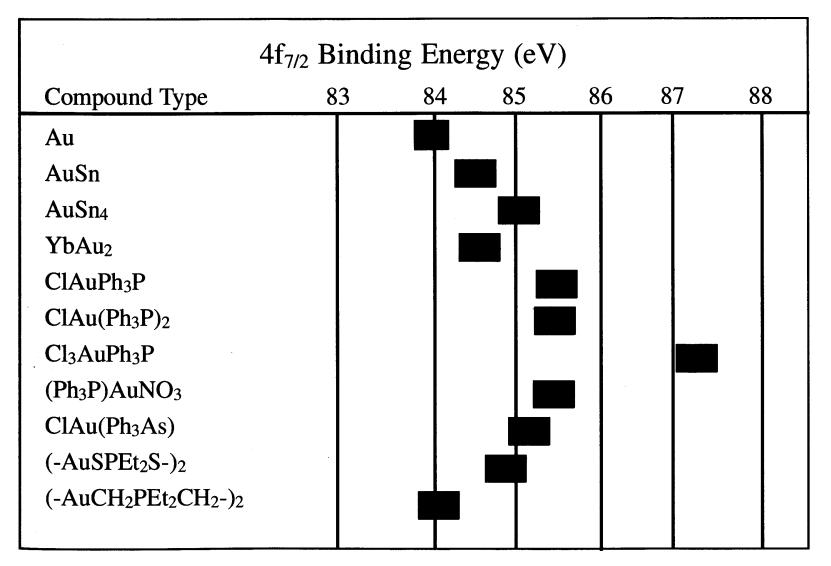




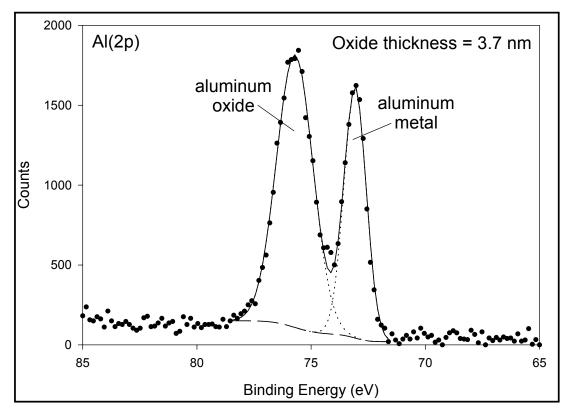
High Resolution Spectra Arsenopyrite



Chemical Shift



Aluminum Oxide Thickness



High resolution AI (2p) spectrum of an aluminum surface. The aluminum metal and oxide peaks shown can be used to determine oxide thickness, in this case 3.7 nanometres.

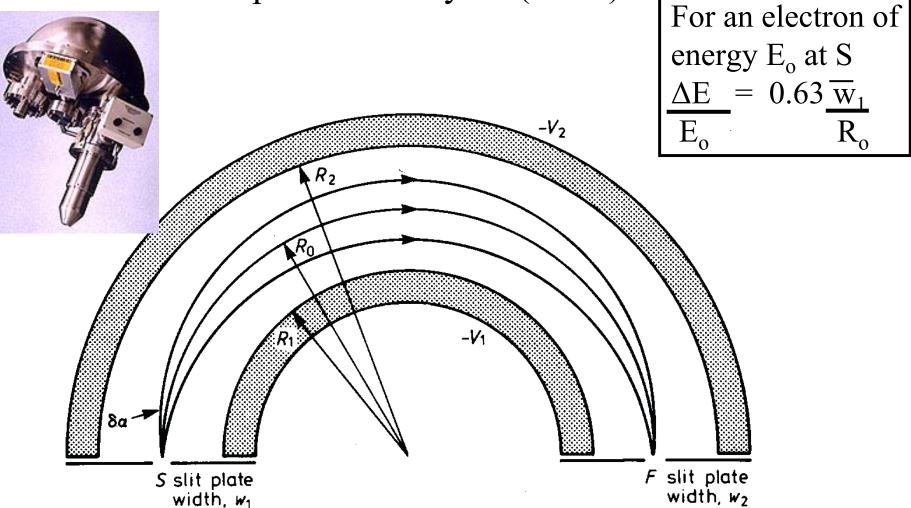
Estimation of Oxide Thickness

- Usually, the binding energies of the oxide and the metallic species are separated by a few electron volts.
- Thus, when the oxide is thin (< 9 nm), it is possible to distinguish the contribution from both oxide and metal photoelectrons.
- For aluminum, oxide thickness (d) is given as:
 - $d (nm) = 2.8 \ln ((1.4(Io/Im))+1)$
 - where Io and Im are the intensities (peak areas) of the oxide and metal photoelectron peaks respectively.

Instrumentation

Electron Energy Analyzer

Concentric hemispherical analyzer (CHA)

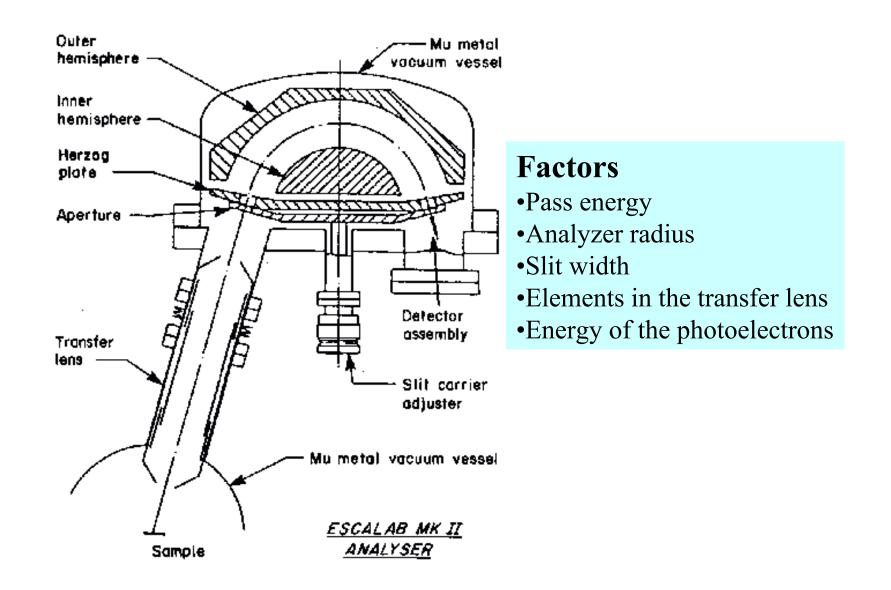


Pass Energies and Transfer Lens

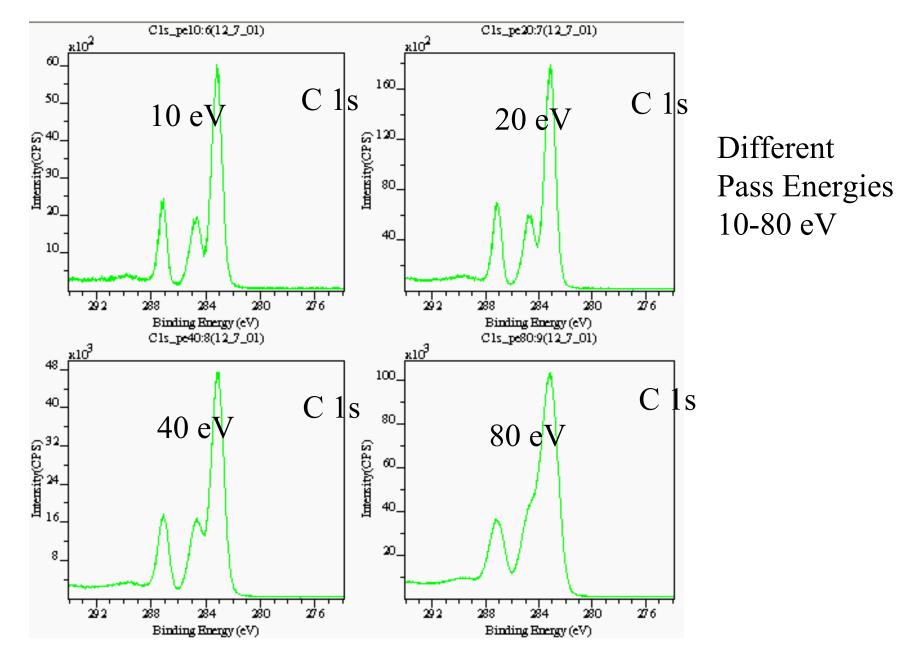
(1) To resolve a 1000 eV electron to ± 0.5 eV would require an analyser with w=1 mm and R=1.2 metres!

Therefore, it is convenient to retard the energy of the incoming electrons so that they have a lower (and constant) energy as they pass through the analyser.

The lens system which retards the electron energy also **<u>focuses</u>** the electrons energy from the sample to increase the throughput.



PET : Polyethylene terephthalate



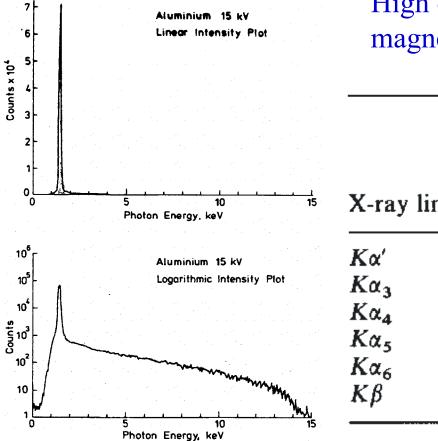
CHA Analysers – Operating Modes

•"CAT" Retardation Mode: Constant Analyser Transmission

- •Characteristics: Constant Pass Energy across spectrum, therefore fixed resolution across spectrum
 - Easier quantitation since transmission is fixed
 - However, fixed transmission works against high KE photoelectrons since most electrons here are scattered
 - narrow acceptance angle
 - Pass Energy α "Entendue"

CRR Mode – Constant Retarding Ratio, not used for XPS

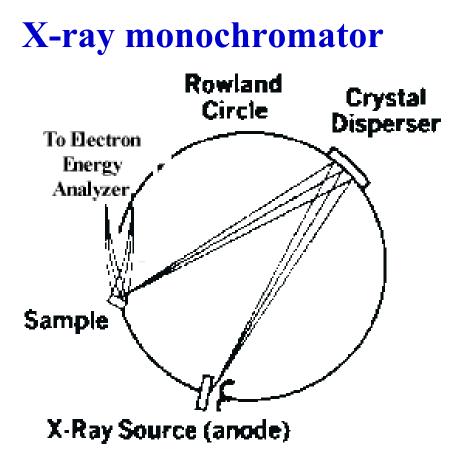




High energy satellite lines from magnesium and aluminium targets

Separation from $K\alpha_{1,2}(eV)$ and relative intensity $(K\alpha_{1,2} = 100)$

X-ray line	Mg	Al	
Κα'	4.5(1.0)	5.6(1.0)	
Κα3	8.4(9.2)	9.6(7.8)	
Κα₄	10.0(5.1)	11.5(3.3)	
$K\alpha_5$	17.3(0.8)	19.8(0.4)	
Ka ₆	20.5(0.5)	23.4(0.3)	
Κβ	48.0(2.0)	70.0(2.0)	



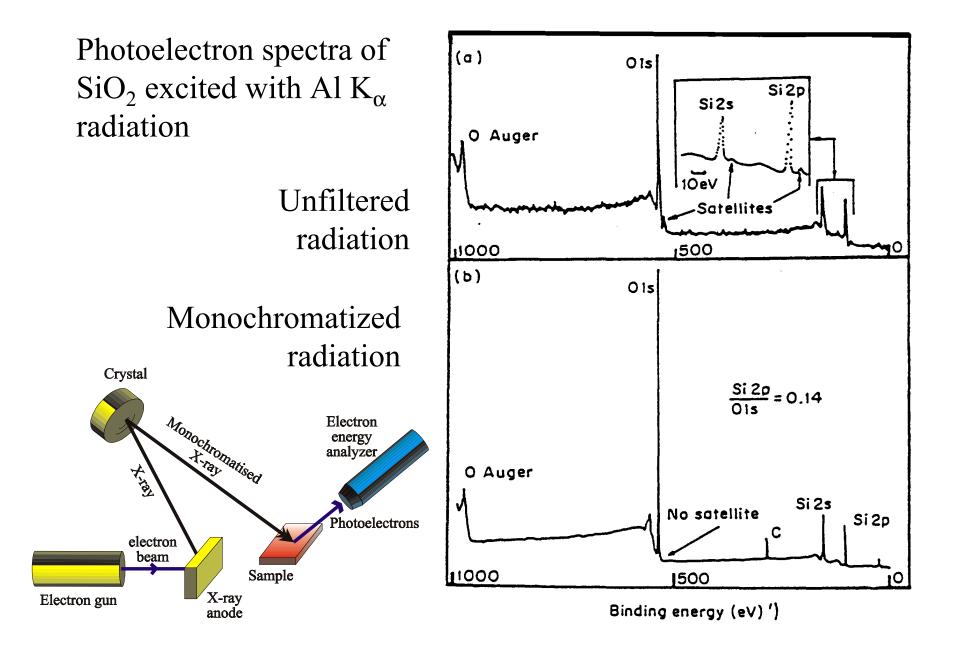
 $n\lambda = 2dsin\theta$

For Al K_{α} $\lambda = 8.3$ Å

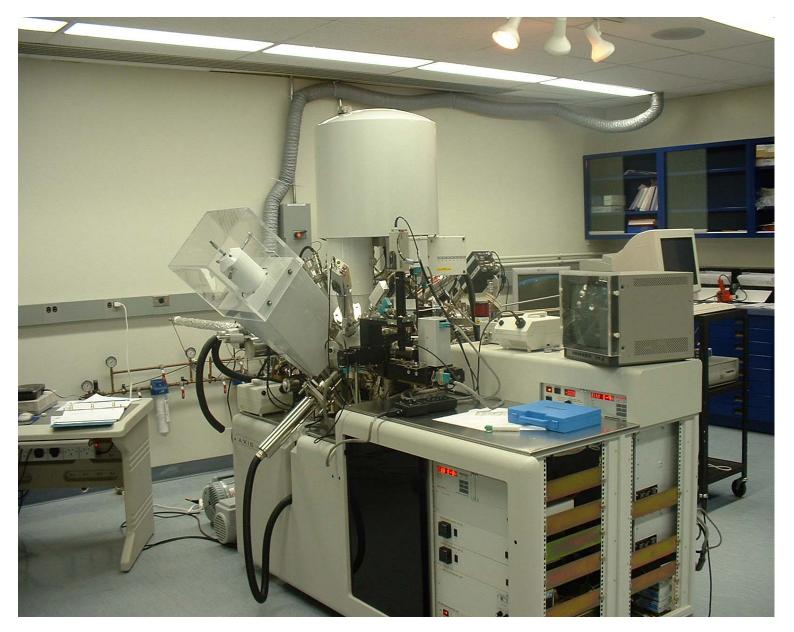
use (1010) planes of quartz crystal d = 4.25Å $\theta = 78.5^{\circ}$

Advantages of using X-ray monochromator

- Narrow peak width
- Reduced background
- No satellite & Ghost peaks



Kratos Axis Ultra at SSW



Photoelectron Line Widths

Contributions to width

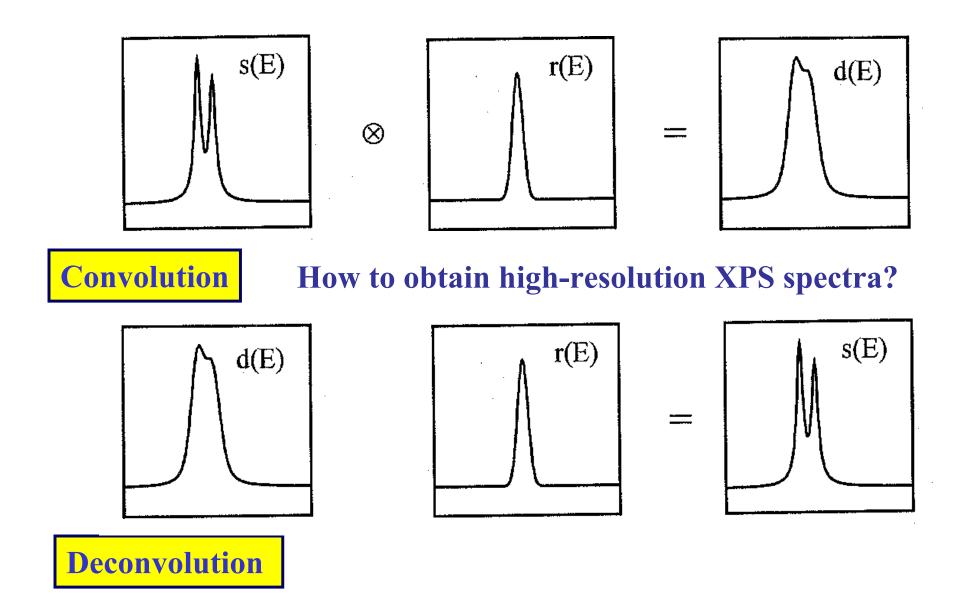
- 1. Inherent linewidth of the photoelectron production event
- lifetime-dependent
- temperature-dependent
- Lorenzian-shape
- 2. Width of Exciting line
- MgK α < AlK α
- Monochromatised AlK α is better. Two component shape is modelled as a Gaussian

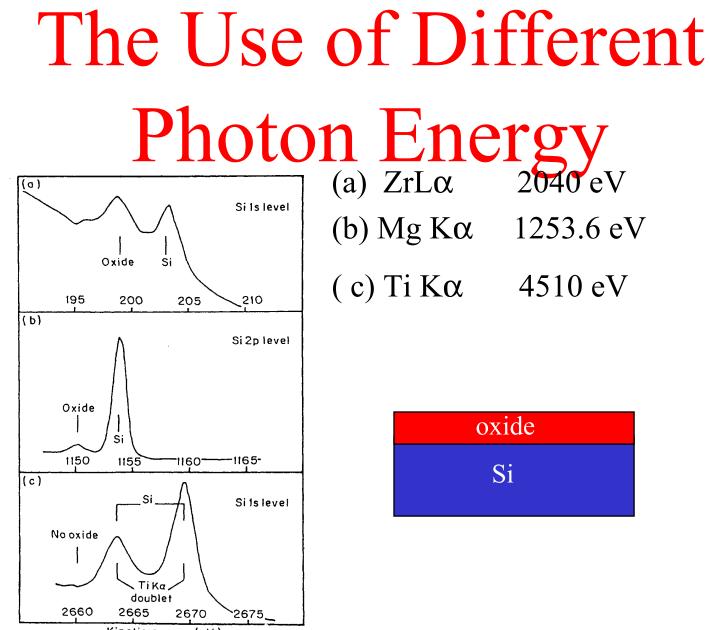
3. Analyser Resolution – determined by pass energy and slit width, modelled as a "box" function.

	2		
	Line	Energy, eV	Width, eV
	ΥΜζ	132.3	0.47
	Zr Mζ	151.4	0.77
	Νb <i>Μ</i> ζ	171.4	1.21
	Μο Μζ	192.3	1.53
ommonly used		395.3	3.0
	$\operatorname{Cr} L\alpha$	572.8	3.0
	Ni $L\alpha$	851.5	2.5
	Cu La	929.7	3.8
	MgKα	1253.6	0.7
	Al Kα	1486.6	0.85
	Si Kx	1739.5	1.0
	Y La	1922.6	1.5
	Zr La	2042.4	1.7
	TiKα	4510.0	2.0
	Cr Ka	5417.0	2.1
	Cu Ka	8048.0	2.6

X-ray lines

Analytical Methods





Kinetic energy (eV)



Energy losses: extrinsic and intrinsic

Electron attenuation: inelastic scattering

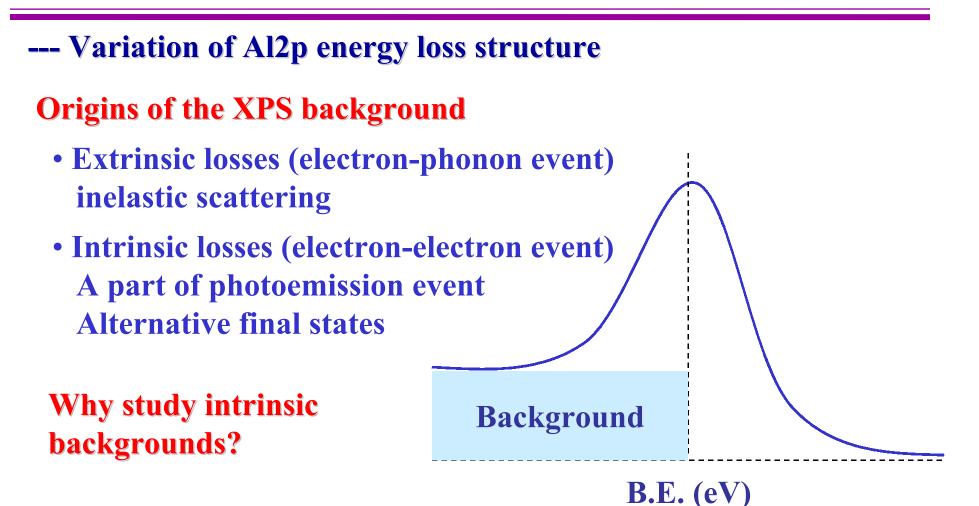
Interpretive models: QASES

Plasmon losses, shake-up and shake-off satellites

Multiplet interactions

Depth profiling

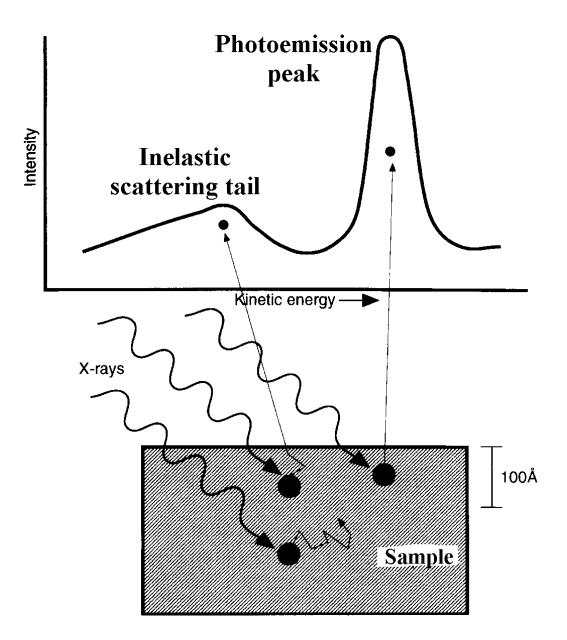
Intrinsic and Extrinsic Losses



• Information about the depth and lateral distributions of elements using the QUASES method developed by Sven Tougaard

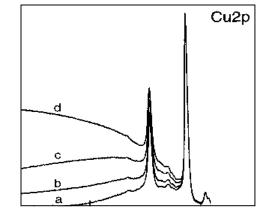
Inelastic Scattering Background

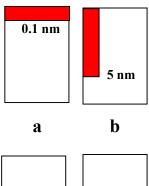
Tougaard developed a fitting procedure for the inelastic scattering tail, which may give some information about the structure of the surface layer, such as, complete coverage by a metal layer or formation of metal clusters.

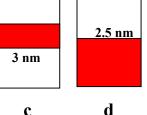


Analysis of XPS Spectra Using QUASES

- Traditional XPS quantification assumes
 - Outer surface of sample is homogeneous
 - Outer surface concentration is directly proportional to the peak intensity
- More accurate quantification should include peak intensity, peak shape and background energy
- In photoelectron spectroscopy electrons detected result from two processes
 - the *intrinsic electrons* from photoelectron process
 - the *extrinsic* electrons from scattering of photoelectrons passing through surrounding atoms
- Depending on the depth of the emitting atom within the surface, as well as its lateral distribution, the extrinsic portion will change dramatically
- The figure shows a theoretical calculation of the extrinsic portion of a copper 2p spectrum as a function of the position and distribution of the emitting copper atoms within a matrix of another element



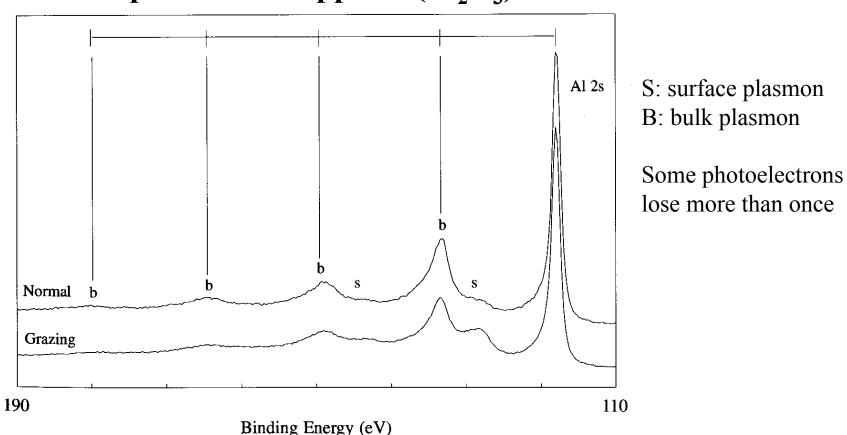




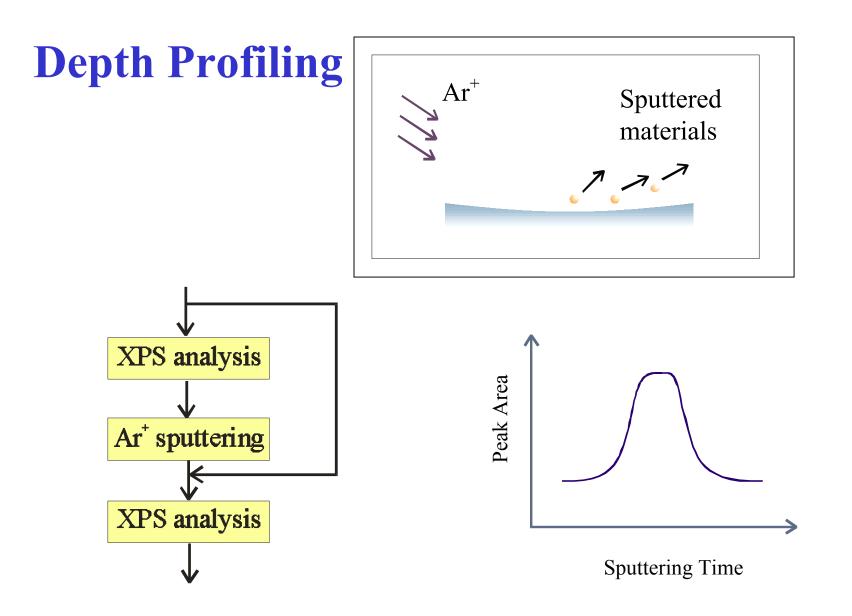
The above example courtesy of <u>www.quases.com</u>

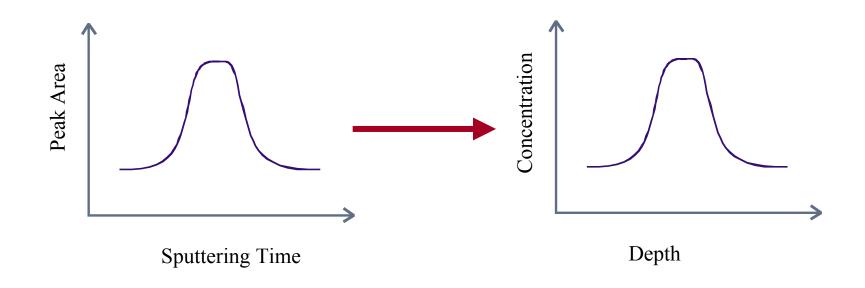
Plasmon Loss Peaks

For some materials, there is an enhanced probability for loss of a specific amount of energy due to interaction between the photoelectron and other electrons.



Al 2s spectrum of sapphire (Al₂O₃)

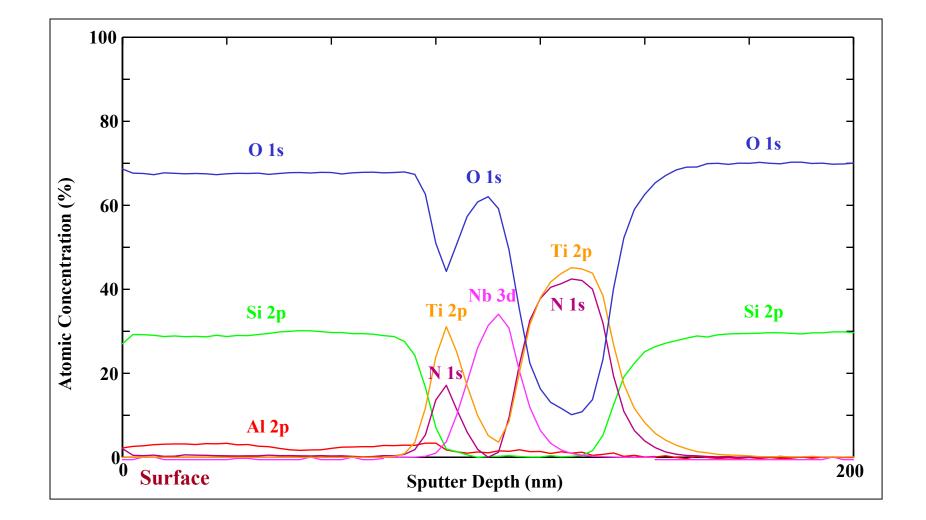


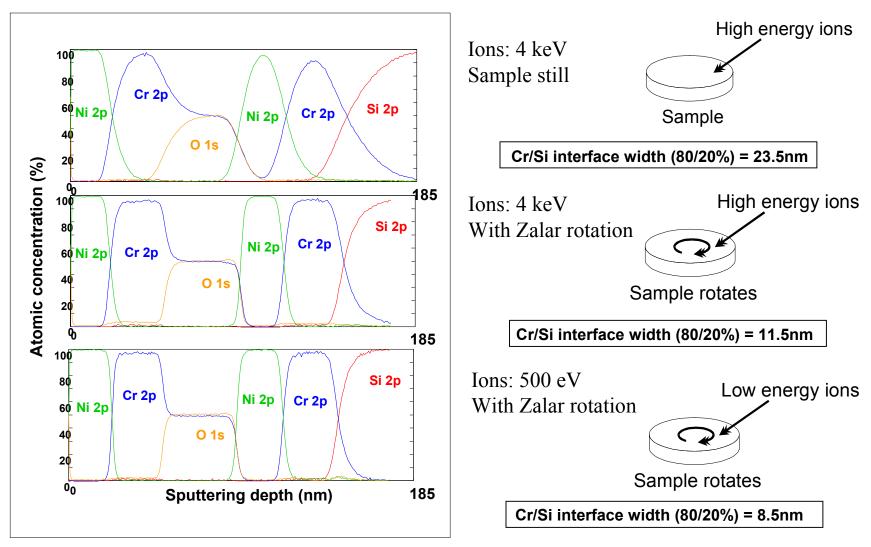


Calibration of depth scale

- 1. Sputtering rate determined from the time required to sputter through a layer of the same material of known thickness.
- 2. After the sputtering analysis, the crater depth is measured using depth profilometer. A constant sputtering rate is assumes.

Depth profile of Architectural Glass Coating





Depth Profile with Sample Rotation

Factor Affecting Depth Profiling

Instrumental factors

Sample characteristics

•Adsorption from residual gas atmosphere

- •Redeposition of sputtered species
- •Impurities in ion beam
- •Non-uniform ion beam intensity
- •Time-dependent ion beam intensity

•Depth information (IMFP)

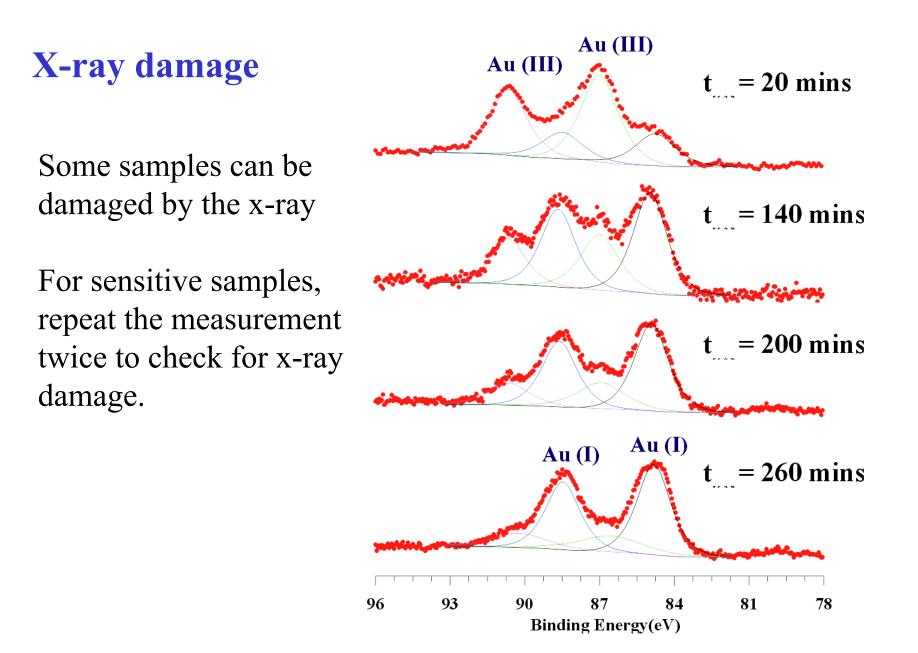
- •Original surface roughness
- •Crystalline structure and defects (Channelling)
- •Alloys, compounds, second phases (Preferential sputtering and induced roughness)

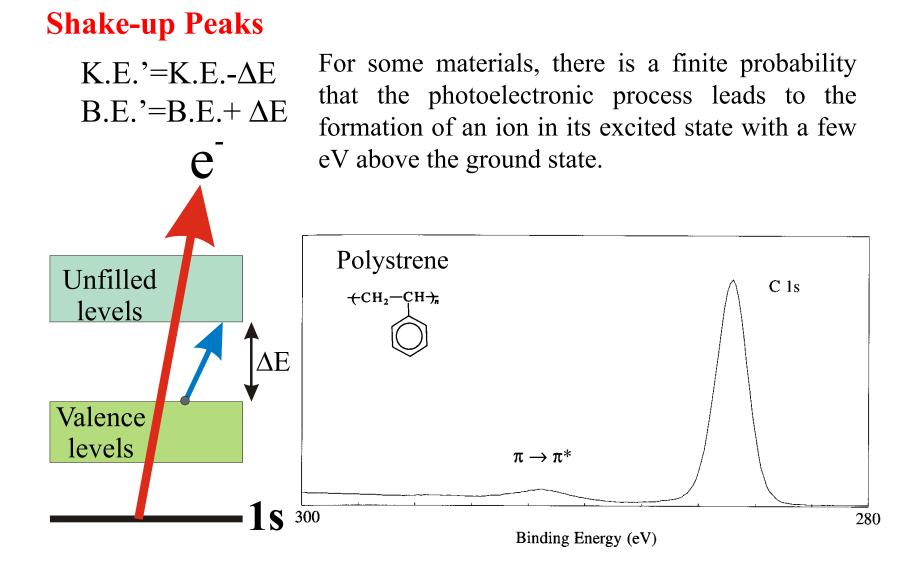
•Primary ion implantation

- Atomic mixing
- Radiation-induced effects •Sputtering-induced roughness

•Preferential sputtering and decomposition of compounds

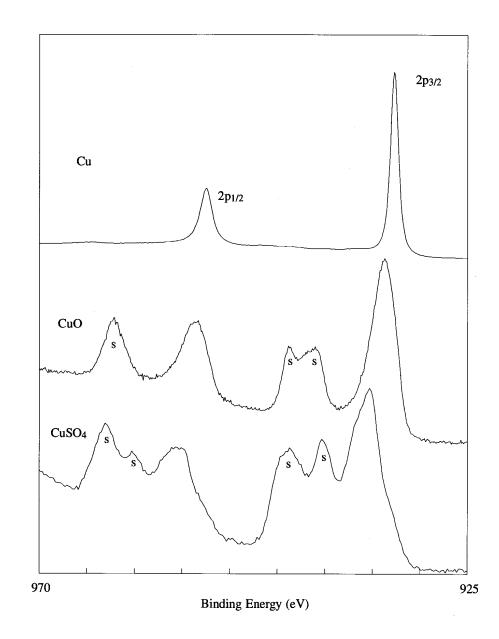
- •Enhanced diffusion and segregation
- •Electron-induced desorption
- •Charging of insulators (analysis distortion; electromigration)







A feature for the identification of Cu (II)



Other Chemical Effects in XPS

FIGURE 5.24. Schematic of multiplet splitting following photoionization in Fe³⁺.

S level interaction

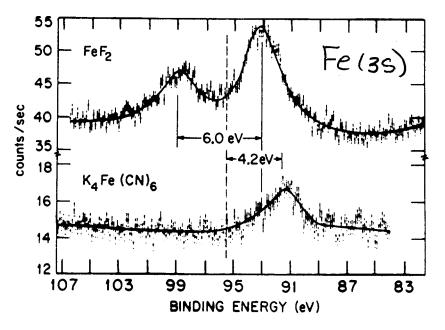
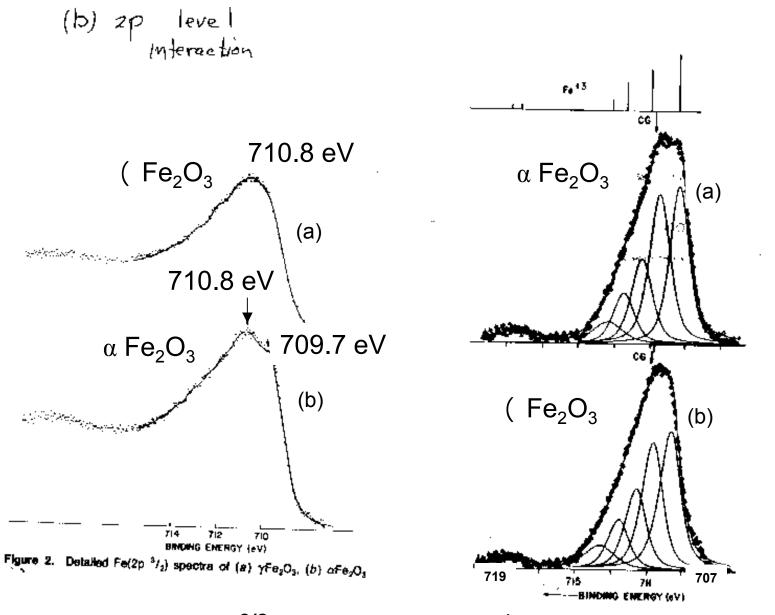


FIGURE 5.25. Photoelectron spectra of 3s shell in some transition metal compounds showing effect of multiplet splitting. [Reproduced from Carver et al., (117) Figure 2.]



Detailed Fe(2p^{3/2}) spectra of (a) (Fe_2O_3 , (b) αFe_2O_3



Sample charging: compensation

Small area analysis and imaging

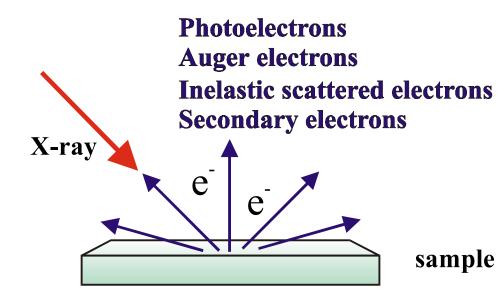
Angle dependent profiling

Modified Auger parameter

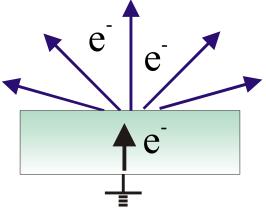
Case studies

Charging Compensation

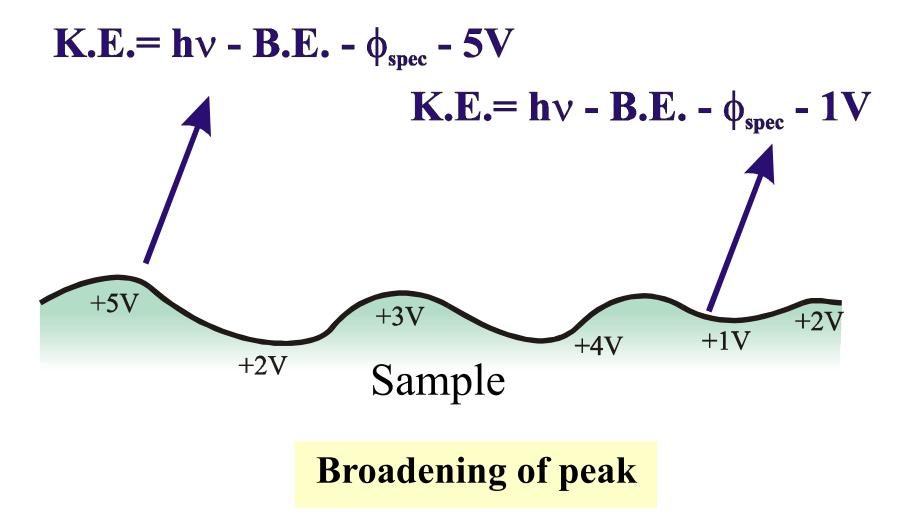
Electron loss and compensation



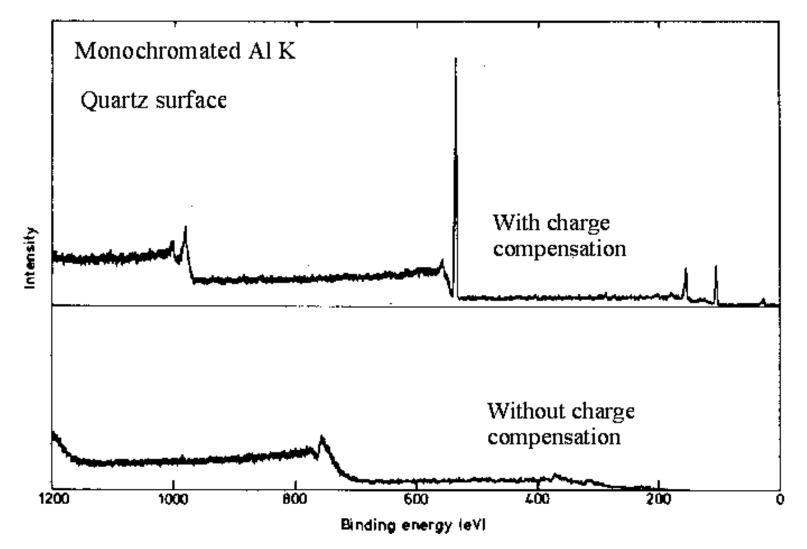
For metal or other conducting samples that grounded to the spectrometer



Electrons move to the surface continuously to compensate the electron loss at the surface region. **Differential (non-uniform) surface charging**

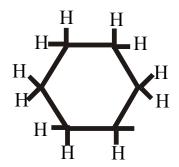


An example of differential surface charging



Binding Energy Referencing technique on insulating samples

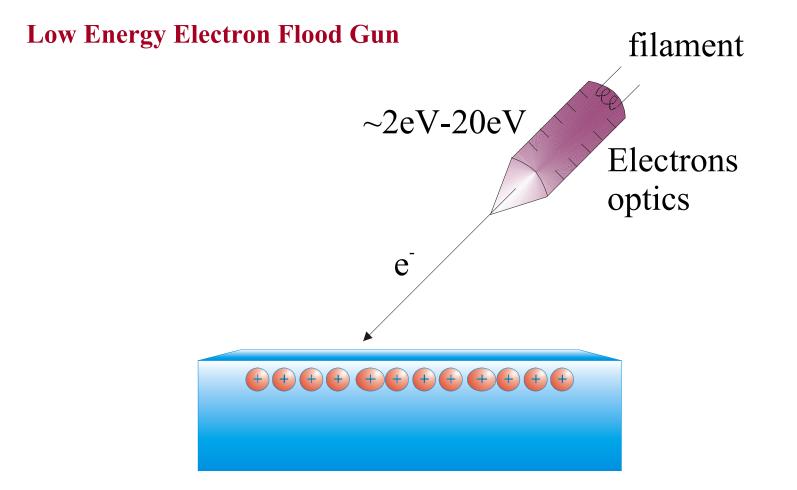
Use of adventitious carbon-based contaminants (i) air exposure (ii) contamination due to pumping oil (iii) add cyclohexane



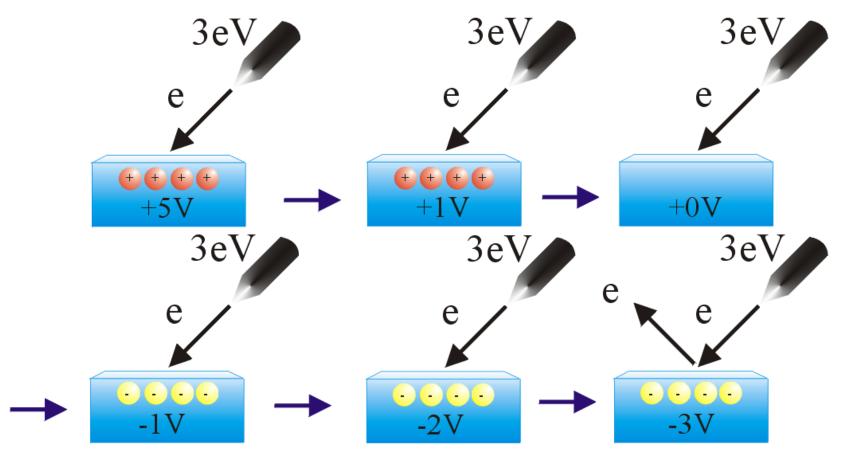
Often used BE = $285.0 \pm 0.2 \text{eV}$ (aliphatic carbon) with referenced to Au $4f_{7/2} = 84.0 \text{eV}$

Or other peaks with known peak position in the sample

Charge Compensation Techniques



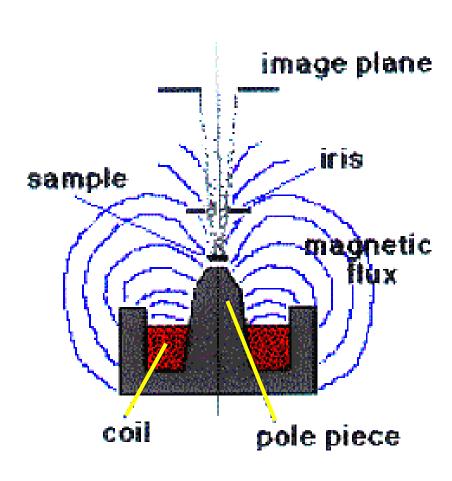
If the electron intensity is high enough



At equilibrium, Surface potential = electron beam energy

Usually, at equilibrium, surface potential < electron beam energy

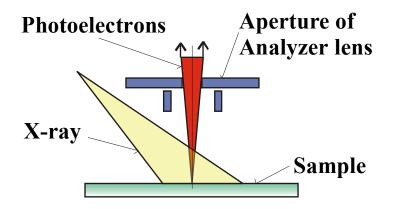
<u>Microscopic Analysis and Imaging Using</u> <u>Photoelectron Spectroscopy</u>



•Strong magnetic immersion fields are used to extract photoelectrons from localized phases.

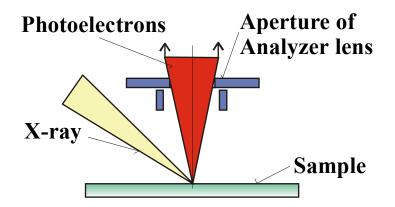
- •High collection efficiency allows images to be acquired within a few minutes.
- Images "corrected" for surface geometry
- •Present resolution $\sim 1 \mu m$
- Spectra can be extracted from regions as small as $15 \ \mu m$

Small area analysis and XPS Imaging

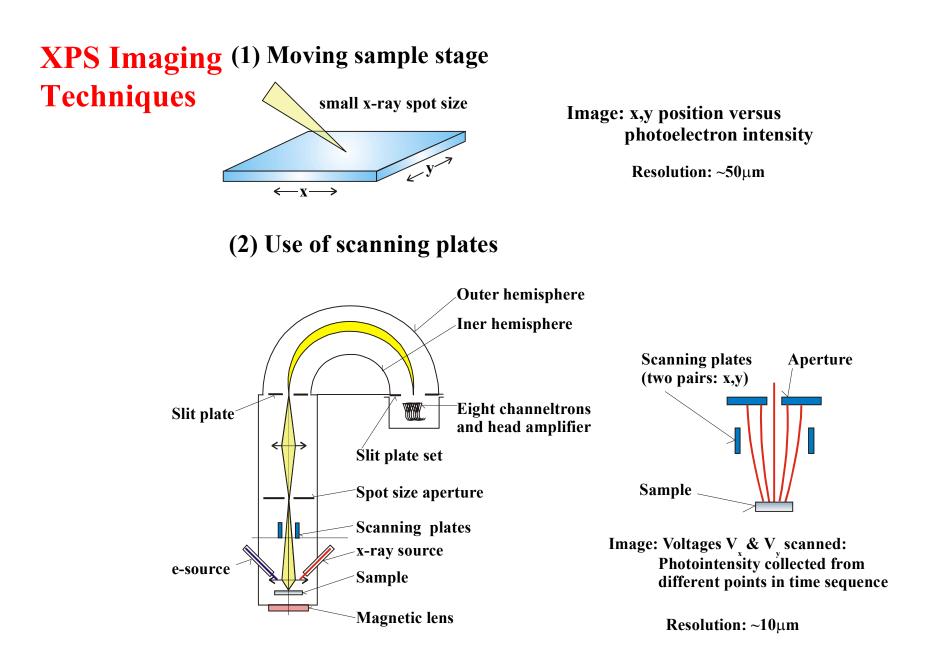


Spot size determined by the analyser

Both monochromated and dual anode x-ray sources can be used

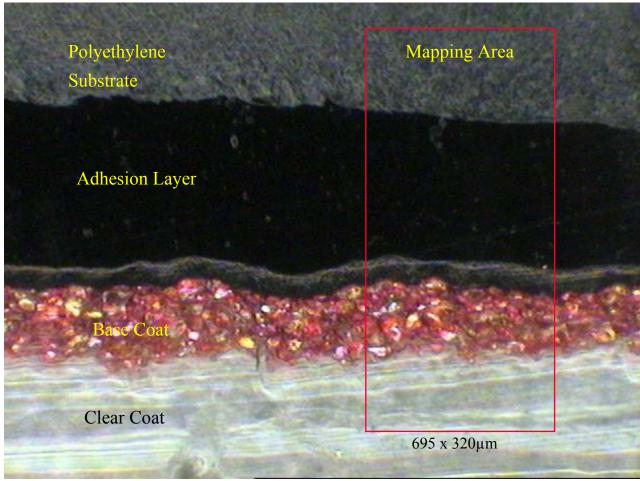


Spot size determined by the x-ray beam



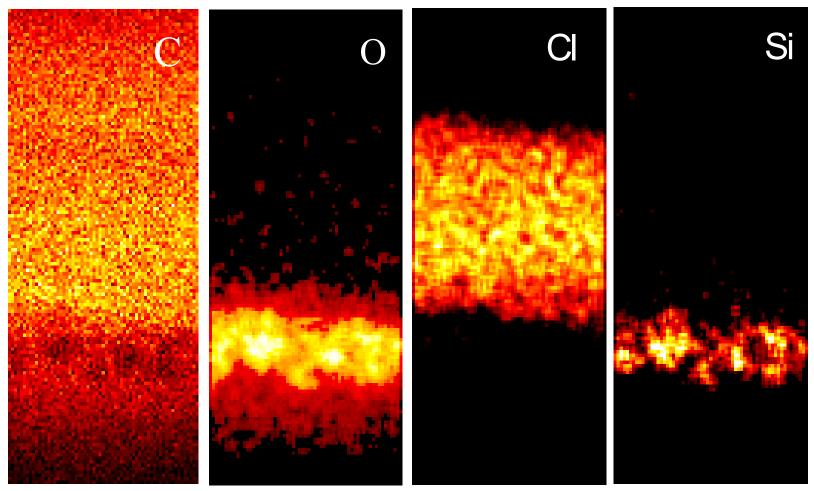
XPS study of paint

SPS photograph of paint cross section



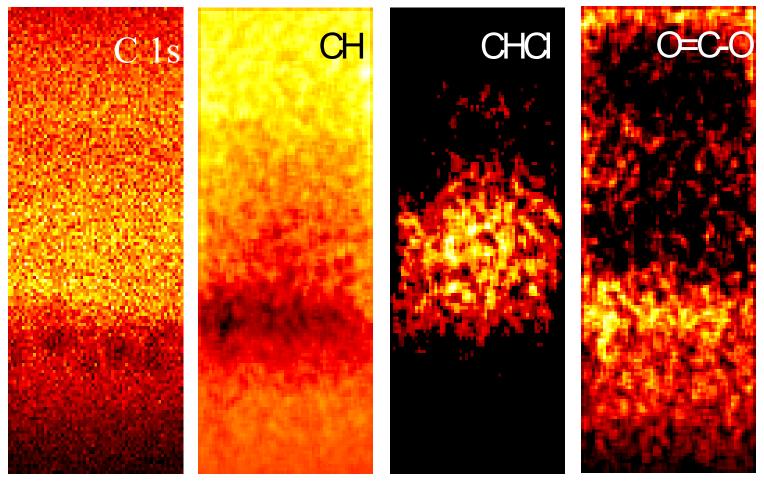
1072 x 812mm

Elemental ESCA Maps using C 1s, O 1s, Cl 2p and Si 2p signals

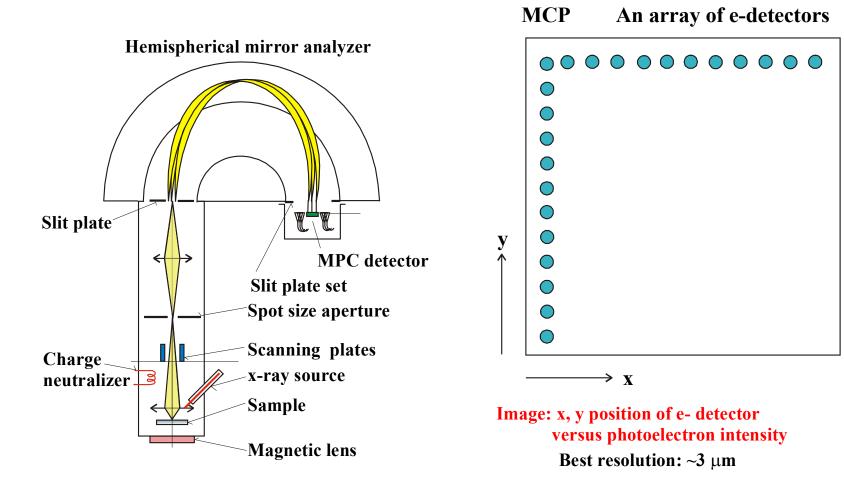


695 x 320mm

C 1s Chemical State Maps

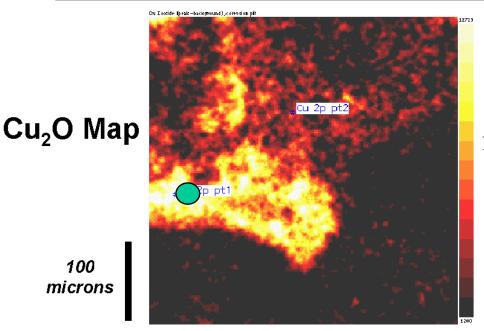


695 x 320mm

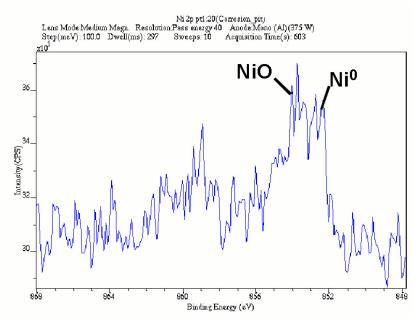


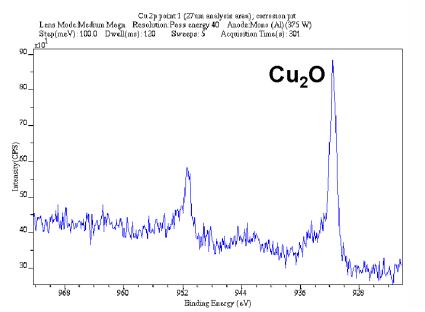
(3) Use of multichannel plate

'Spot' High Resolution Analysis: Cathodic Region?

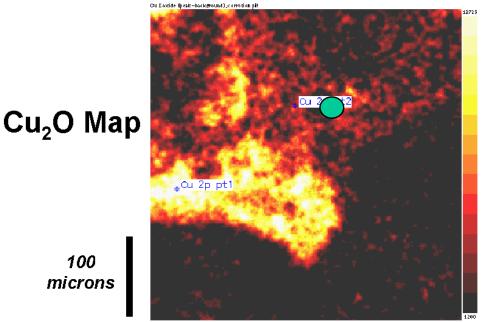


'Spot' chemical state analysis within this map enables identification of a local cathodic site.





'Spot' High Resolution Analysis: Anodic Region?



'Spot' chemical state analysis within this map enables identification of a local anodic site.

